

POBJFKHS Students Earn National Merit Scholarships

Jillian Zhang, Aadi Mehta, and Parshwa Shah Recognized as Among the Top High School Students in the Nation

PLAINVIEW, NEW YORK (April, 2025)— Three seniors from Plainview-Old Bethpage John F. Kennedy High School (POBJFKHS) have been named winners in the prestigious 2025 National Merit Scholarship Competition. Jillian Zhang has been awarded the National Merit Scholarship, while Parshwa Shah and Aadi Mehta have earned corporate-sponsored Merit Scholarships from the Estée and Joseph Lauder Foundation.

This year, only 2,500 students nationwide received National Merit Scholarships, and approximately 770 earned corporate-sponsored awards, selected from a pool of 2.3 million applicants.

The National Merit Scholarship Corporation recognizes the nation's most academically talented students based on exceptional academic records, involvement in school and community activities, and outstanding performance on the PSAT/NMSQT (Preliminary SAT/National Merit Scholarship Qualifying Test).

“We are incredibly proud of Jillian, Parshwa, and Aadi for this extraordinary achievement,” said POBJFKHS Principal Dr. Heather Dvorak. “Their dedication to academic excellence, leadership, and service sets a remarkable example for their peers. This recognition is a testament to their hard work and the support of their teachers and families.”

For more information about the Plainview-Old Bethpage Central School District, please visit the District's website at www.pobschools.org. Exciting activities happening throughout the District and programs celebrating student achievement can also be found on the District's Facebook page at <https://www.facebook.com/pobschools/>.



Jillian Zhang and Aadi Mehta with POBJFKHS Principal Dr. Heather Dvorak and Director of Guidance Laurie Lynn.



Parshwa Shah.